



Attorney's Docket No. 5308-157IP2

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: Das et al.

Confirmation No.: 3570

Serial No.: 10/045,542

Group Art Unit: 1762

Filed: October 26, 2001

Examiner: Michael. E. Barr

For: METHOD OF FABRICATING AN OXIDE LAYER ON A SILICON CARBIDE
LAYER UTILIZING AN ANNEAL IN A HYDROGEN ENVIRONMENT

Date: February 20, 2003

Commissioner for Patents
Washington, DC 20231

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AMENDMENT

Sir:

Applicants provide the present Amendment to address the issues raised in the Official Action mailed November 21, 2002. Applicants provide the present Amendment pursuant to the Revised Amendment Format instituted for the prototype Electronic File Wrapper program described in 1265 Off. Gaz. Pat. Office 87 (Dec. 17, 2002) and that has been expanded to include all Technology Centers and amendments to the specification and drawings. Thus, the provisions of 37 C.F.R. 1.121(a), (b), (c) and (d) are waived for the present Amendment.